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Emulating the paired-pulse facilitation of a biological synapse with a NiOx-based memristor

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Emulating the paired-pulse facilitation of a biological synapse with a NiO$_x$-based memristor

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We study the paired-pulse-induced response of a NiO$_x$-based memristor. The behavior of the memristor is surprisingly similar to the paired-pulse facilitation of a biological synapse. When the memristor is stimulated with a pair of electrical pulses, the current of the memristor induced by the second pulse is larger than that by the first pulse. In addition, the magnitude of the facilitation decreases with the pulse interval, while it increases with the pulse magnitude or pulse width.

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In cognitive neuroscience, it is widely believed that changing the strength or weight of connections between neurons (i.e., synapses) is the mechanism for encoding and storing memory links in the nervous system.¹–³ Solid-state devices that use principles of biological synapses are essential for building cognitive computing systems and mimicking neural networks. Various techniques based on CMOS circuits have been used to implement synapses,⁴–⁶ but such techniques are either inefficient or very complicated. Recently, the memristor has emerged as a promising candidate.⁷–¹⁰ The resistance of a memristor depends on its past states, and this can be used to mimic the synaptic connections in a biological nervous system. Various synapse-like functions of memristors, such as synaptic plasticity,¹¹,¹² spike-time-dependent plasticity,¹³–¹⁶ and self-learning ability,¹⁷–¹⁹ have been reported. A topical review on memristor-based neural networks was recently published by Thomas.²⁰

Figure 1(a) shows a schematic of a biological synapse between a pre-synaptic neuron and a post-synaptic neuron. The synaptic strength is modified by the concentrations of the ionic species (e.g., Na$^+$, Ca$^{2+}$, Mg$^{2+}$) that activate or inhibit the release of neurotransmitters and receptors.² The synaptic enhancement, which is prominent on the timescale of tens to hundreds of milliseconds, is referred to as facilitation. With a pair of stimuli, the second post-synaptic current (or post-synaptic potential) can be up to several times larger than the magnitude of the first, as shown in Fig. 1(a). This effect is usually called paired-pulse facilitation (PPF).²,³ In this work, we demonstrate that the response of a NiO$_x$-based memristor to paired-pulse stimulation resembles the PPF of a biological synapse.

The synthesis of the memristor started with thermal growth of a 400 nm SiO$_2$ thin film on a p-type silicon wafer. After that, a 120 nm Ni layer was deposited on the SiO$_2$ film with electron-beam evaporation. A NiO thin film of ~150 nm was then deposited onto the Ni/SiO$_2$/Si substrate by rf (13.6 MHz) magnetron sputtering of a NiO target (>99.99% purity). The rf power used here was 250 W. Finally, a 150 nm Au/15 nm Ni layer was deposited onto the NiO thin film by electron-beam evaporation to form the top electrode with a diameter of 200 μm. The chemical states of the synthesized nickel oxide thin film were analyzed by a Kratos AXIS x-ray photoelectron spectrometer equipped with monochromatic Al Kα (1486.71 eV) x-ray radiation (12 kV and 15 mA). A Ni$^0$ peak is located within the Ni 2p band, indicating that the as-deposited nickel oxide thin film is Ni-rich. Paired-pulse generation and current measurement were conducted with a Keithley-4200 semiconductor characterization system at room temperature.

The PPF of the memristor is defined with the equation³

$$PPF = 100\% \cdot \frac{(I - I_0)}{I_0},$$

(1)

where $I$ and $I_0$ are the current magnitudes of the second and first pulses, respectively.
where $I_0$ and $I$ are the currents of the first and second pulses, respectively. Figure 2 shows the PPF as a function of the interval between the paired pulses. Here, the pulse magnitude and width were fixed at 1.8 V and 5 ms, respectively. The pulse interval was varied from 5 ms to 2000 ms. The currents $I_0$ and $I$ were measured during the first and second pulses, respectively. For each pulse interval, at least 10 devices at different locations on the wafer were examined, and the statistical distribution of the PPF for each pulse interval is shown in Fig. 2. Note that all the PPF measurements in this work were conducted on virgin devices. As can be observed in the figure, the PPF is positive for all the pulse intervals, showing that the current of the second pulse is always larger than that of the first. This indicates that the effect of the first pulse prolonged the period of the second pulse. However, the PPF decreases gradually with the pulse interval. The average PPF is 105.4% for the interval of 5 ms and decreases to 18.3% for the interval of 2000 ms. This means that the effect of the first pulse faded away gradually during the pulse interval, which suggests that the oxide that had undergone the changes caused by the first pulse could return to its original state if the pulse interval was very long.

The dependence of the PPF of the memristor on the pulse magnitude/pulse width was measured. For each measurement, at least 10 devices at different locations on the wafer were examined. Figure 3(a) shows the PPF as a function of the pulse magnitude with the pulse width and pulse interval fixed at 5 ms and 100 ms, respectively. As can be seen in the figure, the average PPF increases from 7% to 195% when the pulse magnitude increases from 1 V to 3 V. Figure 3(b) shows the PPF as a function of the pulse width with the pulse magnitude and pulse interval fixed at 2 V and 100 ms, respectively. The average PPF increases from 32% for the pulse width of 5 ms to 224% for the pulse width of 1000 ms. The results shown in Fig. 3 can be explained as follows. With a higher pulse voltage or longer pulse duration, more electrical energy was injected into the oxide during the first pulse, causing more local conductive filaments to form and/or the existing filaments to become bigger. This led to a lower oxide resistance, and therefore the current enhancement was larger.

In a biological synapse, PPF decay with pulse interval can be divided into a rapid phase lasting tens of milliseconds (F1) and a slower phase lasting hundreds of milliseconds...
Interestingly, as can be observed in Fig. 2, the dependence of the PPF of the memristor on the pulse interval also shows two-phase behavior, which can be described with the equation

$$PPF = c_1 \cdot \exp(-t/\tau_1) + c_2 \cdot \exp(-t/\tau_2),$$

where $t$ is the pulse-off time (i.e., the pulse interval), $c_1$ and $c_2$ are the initial facilitation magnitudes of the respective phases, and $\tau_1$ and $\tau_2$ are the characteristic relaxation times of the respective phases. The physics for the two phases is not clear yet. In this work, Eq. (2) was used to fit the measured pulse-interval dependence of the PPF. In the fitting, $\tau_1$ should be set smaller than $\tau_2$ because $\tau_1$ and $\tau_2$ represent the rapid and slow phases, respectively; however, all the parameters in Eq. (2) are independent variables. The fitting shown in Fig. 2 yields $c_1 = 30\%$, $c_2 = 72\%$, $\tau_1 = 53$ ms, and $\tau_2 = 1111$ ms. The time scales of the rapid and slow phases of the memristor are similar to those of a biological synapse.

Figure 4 shows the effect of the pulse width/magnitude on the F1 and F2 facilitations. In this experiment, at least 10 devices at different locations on the wafer were examined for each pulse width or magnitude, and $c_1$, $\tau_1$, $c_2$, and $\tau_2$ were obtained by fitting Eq. (2) to the measured PPF data for each magnitude or width. As shown in Figs. 4(a) and 4(c), both $c_1$ and $c_2$ increase with the pulse magnitude or pulse width, indicating that both F1 and F2 facilitations are enhanced with a higher pulse voltage or longer pulse duration. On the other hand, as can be observed in Figs. 4(b) and 4(d), the characteristic relaxation times ($\tau_1$ and $\tau_2$) do not show a clear trend with the pulse magnitude or pulse width.

In conclusion, we have demonstrated that a NiO$_x$-based memristor can emulate the PPF of a biological synapse. The PPF of the memristor increases with both the pulse magnitude and pulse width. Being similar to the behavior of a biological synapse, the PPF decay of the memristor with pulse-off time can be divided into a rapid phase lasting tens
of milliseconds and a slower phase lasting hundreds of milliseconds.

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